

ARIOS INC.

We are the expert of the vacuum and plasma system technology. We support variety of customized production system and equipment for the corporate, academic, and government institution's Research & Development.

Company profile

Business profile **Total solution of ARIOS**

Planning
Our mechanical / electrical engineers will response to your expectation.

Simulation
We are able to suggest to you a suggestion effectively in machine-selection using high performance simulator.

Designing
Our designing team has the latest 2D/3DCAD system and will design suitably.

Manufacturing
From parts cleaning to assembling, we put effort into politely.

Inspection
Our mechanical / electrical engineers complete perfectly.

After Service
Under our guaranty period conditions, we try to resolve all problems promptly. And we are able to support your processes through plasma measurement.

Products of ARIOS

- Plasma units and components
 - CVD (chemical vapor deposition) units
 - Spattering units
 - High vacuum units and components
 - Microwave power supply
 - RHEED system
- and more.

Our Customers **Government office**

National Institute of Advanced Industrial Science and Technology (AIST)
National Institute for Materials Science (NIMS)
Institute of Physical and Chemical Research (RIKEN)
Japan Aerospace exploration Agency (JAXA)
and more.

Domestic and oversea University

Hokkaido University, Tohoku University, The University of Tokyo, Tokyo Institute of Technology, Tokyo Metropolitan University, Nagoya University, Kyoto University, Osaka University, Kyushu University (Japan)
Yonsei University (Seoul, Korea)
and more.

Corporate

Major Japanese and oversea corporations

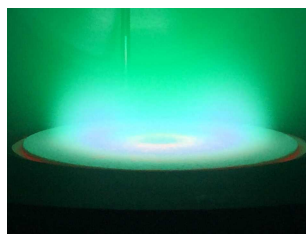
Name ARIOS INC.

Head Office & Factory 3-2-20, Musashino, Akishima City, Tokyo 196-0021, JAPAN

President Osamu Ariyada Ph.D. (Engineering)

Capital 15 million JPY

Board of Directors President Osamu Ariyada Ph.D.
Director Hiroaki Suzuki
Director Atsushi Kanbayashi
Director Kyoko Ariyada
Auditor Takehiro Tomiyoshi



History

1972 TAISEI Industry Corp. funded in Chofu City, Tokyo.

1985 MBE (Molecular Beam Epitaxy) business launched.

1990 Developed UHV (Ultra High Vacuum) Sputter system.

1995 CVD (Chemical Vapor Deposition) business launched.

2001 Rename company name to ARIOS INC.

2002 Relocation of the head office to Akishima City, Tokyo.

2004 Obtained ISO14001 certification.

2015 ARIOS INC. Tokai office opened in Okazaki City, Aichi Prefecture.

2017 Became a consolidated subsidiary of OSG Corporation.
ARIOS INC. Tokai office relocated to Toyokawa City, Aichi Prefecture.

